



**EXPEDITED PROCEDURE – EXAMINING GROUP 2818**

**S/N 10/081,818**

**PATENT**

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Applicant: Jerome M. Eldridge et al.

Examiner: Tu-Tu V. Ho

Serial No.: 10/081,818

Group Art Unit: 2818

Filed: February 20, 2002

Docket No.: 1303.045US1

Title: ATOMIC LAYER DEPOSITION OF METAL OXIDE AND/OR LOW  
ASYMMETRICAL TUNNEL BARRIER INTERPOLY INSULATORS

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**AMENDMENT & RESPONSE UNDER 37 C.F.R. 1.116**

Mail Stop AF  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

In response to the Final Office Action mailed October 5, 2005, please amend the application as follows:

This response is accompanied by a Petition, as well as the appropriate fee, to obtain a two-month extension of the period for responding to the Office action, thereby moving the deadline for response from January 5, 2006 to March 5, 2006.